

IE/SE 590 Syllabus
Seminar; 0 Credit Hours
Fall 2019

Course Administrator: Aleta Lynch
Seminar Chair: Rasoul Etesami

Textbook: None

Meets: Fridays, 10:00 - 10:50 AM; 103 TB

Welcome to the SE/IE 590 seminar course. All on-campus graduate students are required to register for SE 590 (Systems and Entrepreneurial Engineering) or IE 590 (Industrial Engineering) every fall and spring semester.

Students must attend 6 seminars to earn a satisfactory grade. Students who do not earn a satisfactory grade have one semester to make-up the seminars and have the grade changed. If after one semester the seminars have not been completed, the student will automatically receive a "U" (unsatisfactory) grade. The student must still make up the seminars; however, the grade will not be changed until all make-up seminars are completed.

Students may submit a "Seminar Substitution Form" to make up any missed seminars or to count a seminar offered by another department toward the required seminars for this course. This form requires a signature of the staff member in charge (not the speaker). Students may attend 2 non-technical seminars per semester (examples include the resume workshop or SE 290 Engineer in Residence presentation) and count these as part of their total requirements. There will be a mandatory ethics seminar to attend, look for an announcement through an email notification.

An email will be sent one week before the seminar and the morning of the seminar. See these announcements for confirmation of day and time. It is possible that there will not be seminars EVERY Friday or that seminars may be scheduled a different day/time/location. A calendar of the currently scheduled seminars is available at: <http://illinois.edu/calendar/list/3605>. Most seminars will be recorded and are available at: <https://echo360.org>. Watching the online seminars may not be counted toward the total requirements for on campus students.

Learning Objectives

These seminars are presented so that all ISE graduate students are aware of current research and advances in their field.